

Pentacene growth on graphene by in situ GISAXS and GIWAXS

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Abstract

Thin films of small organic semiconducting molecules exhibit attractive optical and electronic properties depending on their molecular structure. Pentacene (PEN) molecules are known to form a lying-down phase on graphene that improves vertical electron transport and increases optical absorption and light harvesting. Here, we studied the mechanism of epitaxial PEN growth on graphene by in-situ GISAXS and GIWAXS techniques complemented by ex-situ AFM and polarized confocal Raman microscopy. Two principal stages of the growth were observed. First, nucleation and growth of PEN islands saturating in width and height at 1 monolayer thickness was observed. Later on, the islands continue to grow only along [100] direction of the PEN triclinic lattice adopting needle-like shape and copying hexagonal symmetry of the underlying graphene. The c^* axis of PEN reciprocal lattice was found to be parallel to the [210] (armchair) direction of graphene and tilted by 18° with respect to the graphene surface. This suggests a $\approx 11^\circ$ deviation of the PEN molecular chains from the graphene surface driven by the energy minimization in later stages of the islands growth.

Introduction

Thin films of small organic molecules are attractive for applications in light-emitting diodes, field-effect transistors or organic solar cells. The device performance critically depends on the molecular structure of the film which in turn depends on the substrate type. For the oxide surfaces such as SiO_2 , the standing-up configuration is typical. In the last decade it has been shown that templating the substrate with two-dimensional materials, the lying-down configuration can be achieved. Hence, this approach offers a possibility to control the molecular orientation and properties of the small molecule organic films. Indeed, the lying-down configuration of pentacene (PEN) molecules after evaporation on graphene was observed. PEN is an archetypal type of small organic molecules that are frequently used in organic electronics and photovoltaics. In order to optimize preparation of PEN films with the lying-down configuration, a study of the mechanism of PEN growth on graphene is needed. This gave impetus for the work presented here.

Experimental details

The PEN molecules (Sigma-Aldrich) were thermally evaporated onto epitaxially grown graphene on hexagonal 4H-SiC(0001) substrate (Graphsensic) in a deposition chamber that was equipped with a beryllium window for the in-situ grazing-incidence small-angle and wide-angle X-ray scattering (GISAXS, GIWAXS) experiments. The deposition rate was $1.38 \text{ \AA}/\text{min}$. The in-situ GISAXS/GIWAXS measurements were done at the 0.1° angle of incidence at ID10 (9.25 keV) and PO3 (11.4 keV)

synchrotron beamlines at ESRF Grenoble and DESY Hamburg, respectively. Two hybrid pixel detectors acquired simultaneously and repeatedly the GIWAXS and GISAXS patterns during the evaporation (Maxipix and Pilatus 300K at ESRF, Pilatus 300K and Pilatus 1M at DESY). The 60 s integration time used at ESRF was reduced to 100 ms at DESY to capture initial stages of the deposition. The ex-situ GIWAXS measurements were done on a custom-designed Nanostar X-ray setup (Bruker AXS) equipped with a Ga liquid-metal jet anode X-ray source Excillum (9.25 keV) at an angle of incidence of 0.15° with a Pilatus 300K detector. The AFM measurements (Bruker, Dimension Edge) were done in tapping mode and the polarized Raman measurements were performed on a confocal Raman microscope (Witec, Alpha300 R+)

Results and conclusions

The ex-situ GIWAXS pattern after the PEN film deposition shows 3 diffraction spots (Fig. 1a). The film thickness calculated from the deposition rate and time corresponds to that of 10 PEN monolayers (MLs) reported previously [1]. The diffraction spots have no symmetric counterparts on the opposite side of the

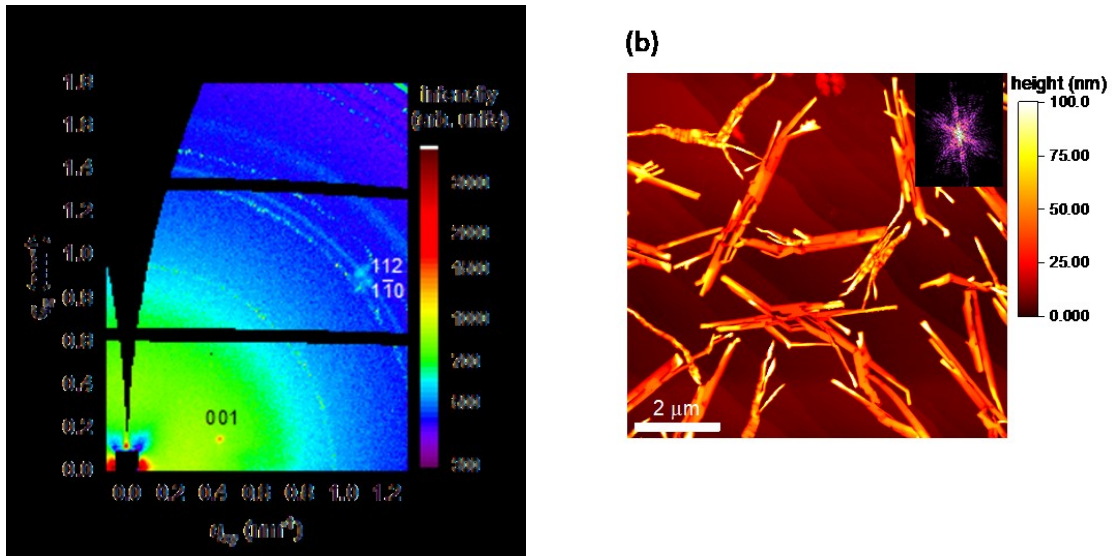


Figure 1. (a) GIWAXS pattern of PEN film and (b) its AFM image with Fourier transform in the inset.

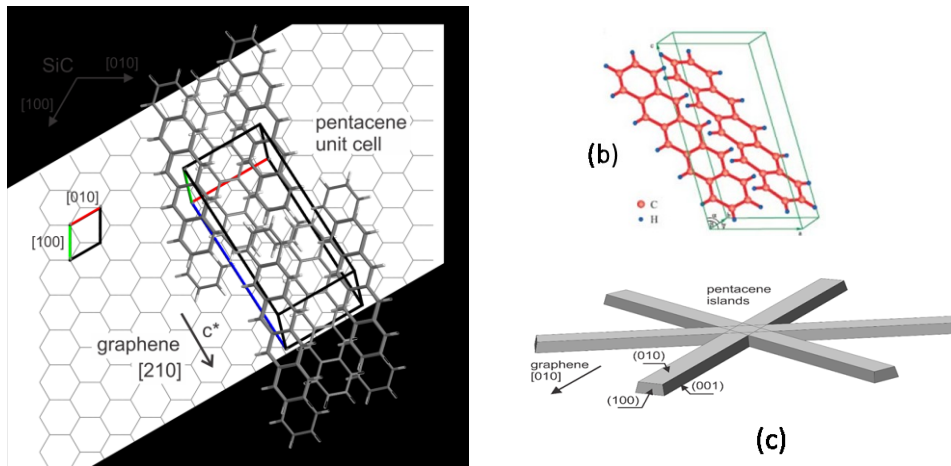


Figure 2. (a) Mutual orientation of PEN and graphene lattices. (b) PEN unit cell and (c) crystallographic orientation of PEN islands.

pattern (not shown) suggesting a monocrystalline structure of the film. It is composed of PEN crystals forming needle-like islands that follow hexagonal symmetry of the underlying graphene (Fig. 1b). The hexagonal unit cell of epitaxially grown graphene on SiC is rotated by 30° from the SiC hexagonal unit cell. Supposing the triclinic PEN phase [2], the orientation of PEN lattice with respect to graphene can be thus found from the ex-situ GIWAXS pattern (Fig. 2a). The reciprocal c^* axis of PEN crystal is aligned along [210] (armchair) graphene direction and tilted by 18° from the graphene surface. The crystallographic a axis of the PEN unit cell lies in the graphene plane. Taking into account the PEN molecule orientation in the unit cell (Fig. 2b), the long molecular axis does not follow the [100] (zigzag) graphene direction but is tilted by 11° . This is due to energy minimization in the presence of intermolecular interactions in three-dimensional PEN crystals. The blurred $1\bar{1}0$ and 112 diffraction spots (Fig. 1a) originate from the crystals rotated by 120° and 300° (Fig. 2c). The ex-situ polarized confocal Raman microscopy revealed a uniform orientation of PEN molecular chains inside the islands, confirming thus their monocrystalline structure (Fig. 3).

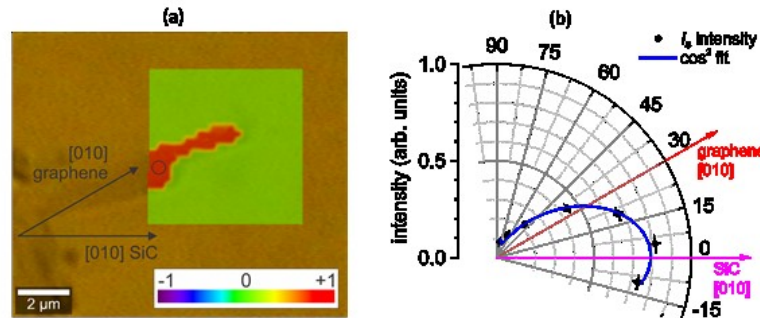


Figure 3. (a) Overlap of the optical and Raman images of a PEN island and (b) $\cos^2$ fit of the azimuthal dependence of Raman band integral intensity at 1373 cm^{-1} (short molecular axis vibrations) inside the black circle in (a).

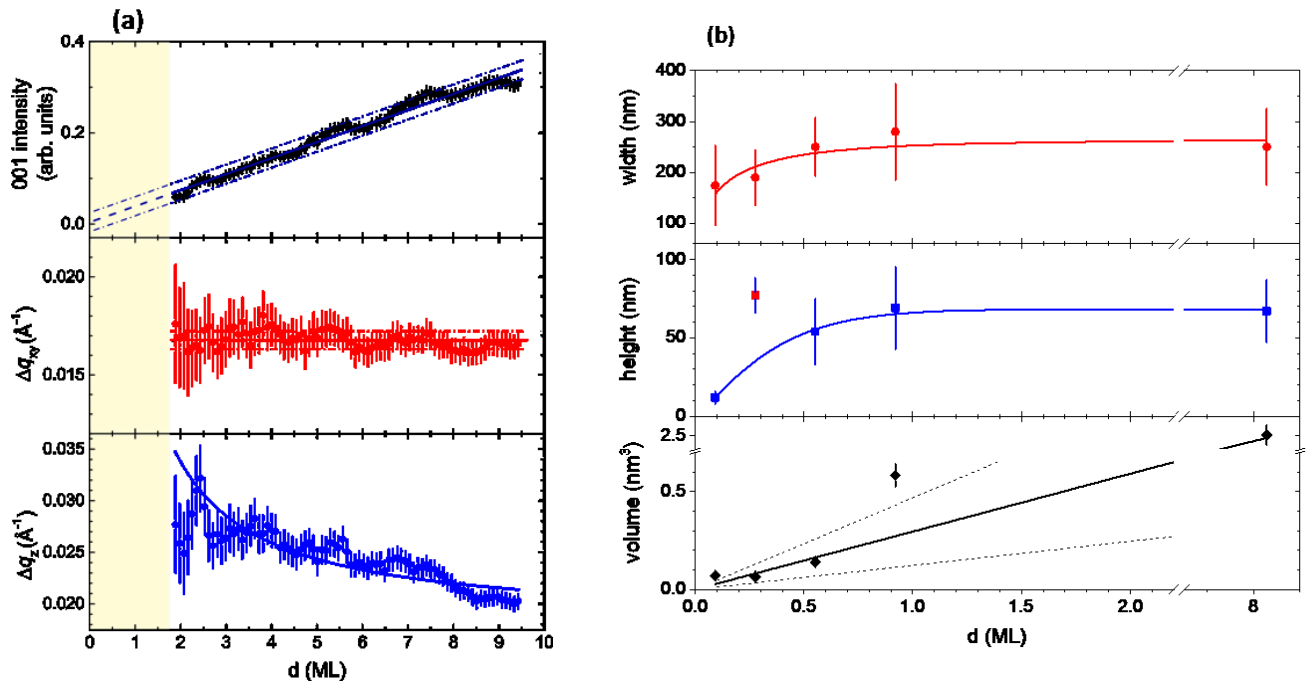


Figure 4. (a) Temporal evolution of PEN 001 diffraction peak parameters and (b) dimensions of PEN islands. (dots - measured points, lines - fits)

The temporal evolution (in the number of deposited MLs) of the integral intensity of 001 diffraction extrapolated to zero thickness indicates a linear growth of the lying-down phase from the very beginning of deposition (Fig. 4a) when the scattered intensity was too low to be measured (yellow region). While the lateral Δq_{xy} width of 001 diffraction spot is controlled by the limited resolution at grazing incidence, Δq_z shows an increase in islands height from 25 nm to 44 nm between 2.5 and 8 MLs before the resolution limit is reached (Fig. 4a). The temporal evolution of the islands dimensions evaluated from AFM images taken ex-situ at selected deposition times suggests a strongly asymmetric growth due to the saturation of the islands width and height at 1 ML thickness (Fig. 4b). The asymmetry is driven by different surface energies of (001), (010) and (001) facets (Fig. 2c) that are 3.1, 4.8 and 6.4 meV/Å², respectively.

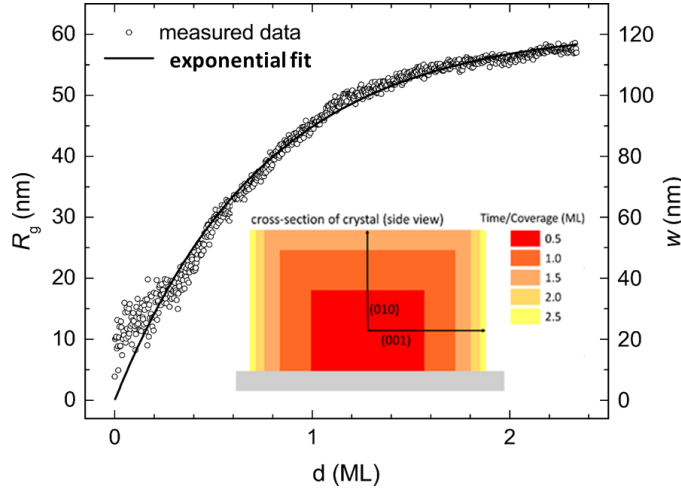


Figure 5. Temporal evolution of the radius of gyration $R_g = \frac{1}{2} w$ (w – PEN islands width). The inset shows the growth of (100) facets.

The kinetics of PEN crystals growth was studied by in-situ GISAXS. It could be measured simultaneously with GIWAXS as the in-plane Bragg angle of 001 diffraction was slightly deviated from the graphene zigzag direction (Fig. 2a). Due to the low PEN islands density and large interisland distances exceeding experimental GISAXS resolution, the measured GISAXS curve is primarily controlled by the interplay of three form factors corresponding to three different crystal orientations (Fig. 2c). Hence, it could be evaluated by Guinier analysis. As a consequence of the highly anisotropic crystals growth, these form factors contribute to GISAXS curve in different q ranges. Consequently, Guinier analysis in a q range of $(1 \div 2) \times 10^{-3} \text{ Å}^{-1}$ allowed to analyze the temporal evolution of the radius of gyration which could be attributed to a half of the islands width (Fig. 5). A fit with a simple exponential limited growth function provided a rate constant of $(3.5 \pm 0.03) \times 10^{-3} \text{ s}^{-1}$. Combining these results with AFM data, the growth of (100) facets (Fig. 2c) can be visualized (inset in Fig. 5).

Summarizing, a comprehensive time-resolved study of PEN thermal evaporation on a large-area graphene monolayer on SiC revealed a highly anisotropic epitaxial two-stage growth of a laying-down phase in the form of elongated islands following hexagonal symmetry of the substrate. The PEN islands possess triclinic monocrystalline structure, the long molecular axis being deviated from graphene by 11° in the final stage.

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